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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/687,967	10/20/2003	Marie Hiraizumi	OK1.591	8642
20987	7590 03/29/2005	EXAMINER		
	E FRANCOS, & WHI	MANDALA, VICTOR A		
ONE FREEDOM SQUARE 11951 FREEDOM DRIVE SUITE 1260 RESTON, VA 20190			ART UNIT	PAPER NUMBER
			2826	

DATE MAILED: 03/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/687,967	HIRAIZUMI, MARIE				
Office Action Summary	Examiner	Art Unit				
	Victor A. Mandala Jr.	2826				
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with the	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REI THE MAILING DATE OF THIS COMMUNICATIOI - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory peri - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply be t reply within the statutory minimum of thirty (30) datiod will apply and will expire SIX (6) MONTHS fror tute, cause the application to become ABANDON	imely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 04	1 February 2005.					
2a) This action is FINAL . 2b) ☑ T	his action is non-final.					
3) Since this application is in condition for allow closed in accordance with the practice under	·					
Disposition of Claims						
4) ☐ Claim(s) 1-6 is/are pending in the applicatio 4a) Of the above claim(s) is/are without 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-6 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and	Irawn from consideration.					
9) The specification is objected to by the Exam	iner.	•				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to t	, , ,					
Replacement drawing sheet(s) including the corr	ection is required if the drawing(s) is o	bjected to. See 37 CFR 1.121(d).				
11)☐ The oath or declaration is objected to by the	Examiner. Note the attached Offic	e Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s)	4) ☐ Interview Summar	v (PTO-413)				
Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail D	Date				
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date <u>2/4/05</u>. 	5) Notice of Informal 6) Other:	Patent Application (PTO-152)				

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DETAILED ACTION

Claim Objections

Claims 1-3 are objected to because of the following informalities:

The claims are objected to because the equation does not detail what the measurement units of 9.29 * 10¹⁵ is and for 62.46. These are necessary in order to properly calculate the results.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-6 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent Application Publication No. 2003/0227056 Wang et al.

1. Referring to claim 1, a semiconductor device comprising: a substrate, (Figure 13 & 19 #50), having an insulating layer, (Figure 13 & 19 #56), formed thereon; a silicon layer, (Figure 13 & 19 #55 & 62), having a thickness ts formed on the insulating layer, (Figure 13 & 19 #56), the silicon layer, (Figure 13 & 19 #55 & 62), including a first area having a first impurity concentration of Df cm⁻³, (Paragraph 0041), and a second area having a second condition of Dp cm⁻³, (Paragraph 0041); a fully-depleted MOSFET formed in the first area of the silicon

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substrate, (Figure 13 & 19 #55 & 62); and a partially-depleted MOSFET formed in the second area of the silicon layer, (Figure 13 & 19 #55 & 62); wherein the semiconductor device satisfies the following condition: $28 \text{ nm} \le \text{ts} \le 42 \text{ nm}$

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$$Df \le 9.29 * 10^{15} * (62.46 * ts)$$

$$Df \le 2.64 * 10^{15} * (128.35 * ts)$$

$$Dp \ge 9.29 * 10^{15} * (62.46 * ts)$$

 $Dp \ge 2.64 * 10^{15} * (129.78 * ts)$, (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).

- 2. Referring to claim 2, a semiconductor device, wherein the device satisfies condition of Df \leq 3.00 * 10¹⁵ * (102.67 * ts), (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).
- 3. Referring to claim 3, a semiconductor device, wherein the device satisfies condition of $Dp \ge 3.29 * 10^{15} * (125.70 * ts)$, (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).
- 4. Referring to claim 4, a semiconductor device, wherein the thickness of the silicon layer has a range 38 nm to 42 nm, the impurity concentration Df is equal or more than 1.9 * 10¹⁷ cm⁻³, and the impurity concentration Dp is equal or less than 2.2 * 10¹⁷ cm⁻³, (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).
- 5. Referring to claim 5, a semiconductor device, wherein the thickness of the silicon layer has a range 33 nm to 37 nm, the impurity concentration of Df is equal or less than 2.5 * 10¹⁷ cm⁻³, and the impurity concentration Dp is equal or more than 2.7 * 10¹⁷ cm⁻³, (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).
- Referring to claim 6, a semiconductor device, wherein the thickness of the silicon layer has a range 28 nm to 32 nm, the impurity concentration of Df is equal or less than $2.7 * 10^{17}$

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cm⁻³, and the impurity concentration Dp is equal or more than 3.2 * 10¹⁷ cm⁻³, (Paragraph 0045 Lines 3-5 & Paragraph 0056 Lines 15-16).

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Victor A. Mandala Jr. whose telephone number is (571) 272-1918. The examiner can normally be reached on Monday through Thursday from 8am till 6pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

VAMJ 3/10/05

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